L Number		Search Text	DB	Time stamp
-	26032		USPAT;	2004/04/17 18:23
		mask same (pattern aperture)	US-PGPUB	
-	2	((pr photoresist photo?resist polymer\$3)	USPAT;	2004/04/17 17:55
		same mask same (pattern aperture)) and	US-PGPUB	
		(stretch\$3 with mask with align\$3 with		
	·	substrate)		
-	2	stretch\$3 with mask with align\$3 with	USPAT;	2004/04/17 17:56
		substrate	US-PGPUB	
-	20	stretch\$3 same mask same align\$3 same	USPAT:	2004/07/15 11:22
	,	substrate	US-PGPUB	
-	8	stretch\$3 same mask same align\$3 same	EPO; JPO;	2004/04/17 18:07
	,	substrate	DERWENT;	
	,		IBM TDB	
_	3	reposition\$6 near35 polymer\$3 near5 mask	USPAT;	2004/07/14 17:44
	_		US-PGPUB	
_	8095	(TFT and (resist pr photoresist))	USPAT:	2004/07/14 17:45
	_ ,		US-PGPUB	,,
-	6584	((TFT and (resist pr photoresist))) and mask	USPAT:	2004/07/14 17:45
		,	US-PGPUB	,,
_	1919	(((TFT and (resist pr photoresist))) and	USPAT;	2004/07/15 15:09
		mask) and aperture	US-PGPUB	,,
-	21	stretch\$3 same mask same align\$3 same	USPAT;	2004/07/15 11:25
		substrate	US-PGPUB	
_	10520	deposit\$3 near20 using near20 mask\$3	USPAT;	2004/07/15 13:14
		,	US-PGPUB	=====================================
_	1246	(deposit\$3 near20 using near20 mask\$3) and	USPAT;	2004/07/15 13:16
		(TFT (thin near3 film near3 transistor))	US-PGPUB	
-	196	deposit\$3 near50 using near50 polymer\$3	USPAT;	2004/07/15 13:15
		near50 mask\$3	US-PGPUB	=====================================
-	18	(deposit\$3 near50 using near50 polymer\$3	USPAT;	2004/07/15 13:53
		near50 mask\$3) and (TFT (thin near3 film	US-PGPUB	,,
		near3 transistor))		
-	2	1	USPAT:	2004/07/15 13:52
	_	- · · · · · · · · · · · · · · · · · · ·	US-PGPUB	====, ==, ==, ===
_	8501	((polymer organic) near50 mask)	USPAT;	2004/07/15 13:55
			US-PGPUB	1313, 11, 25 25155
_	1073	(((polymer organic) near50 mask)) and (TFT	USPAT;	2004/07/15 13:55
		(thin near3 film near3 transistor))	US-PGPUB	=====================================
_	9406	((polymer\$3 organic) near50 mask)	USPAT;	2004/07/15 13:55
			US-PGPUB	,,
_	1115	(((polymer\$3 organic) near50 mask)) and (TFT	USPAT:	2004/07/15 13:56
		(thin near3 film near3 transistor))	US-PGPUB	====, ==, ==,
_	27	(((TFT and (resist pr photoresist))) and	EPO; JPO;	2004/07/15 15:34
		mask) and aperture	DERWENT;	,,
		· · · · · · · · · · · · · · · · · · ·	IBM TDB	
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